



PATENT

41935

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Akiko HEMMI et al.

Serial No.: 09/887,345

Filed: June 25, 2001

For: LOW-MOLECULAR (METH)ACRYLIC  
ACID (SALT)-BASED POLYMER AND ITS  
PRODUCTION PROCESS AND USES

Group Art Unit: 175

Examiner: B. Mruk

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**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with 37 C.F.R. § 1.97 and § 1.98, Applicants bring the disclosures attached and listed on completed Form PTO-1449 to the Examiner's attention and request that they be considered and made of record in this application.

The enclosed patents were cited in Applicants' corresponding Chinese application, and a copy of a Notice on Office Action from the Chinese Patent Office dated April 11, 2003, and English translation thereof, is enclosed.

CN 1251846 corresponds to U.S. Patent Application Pub. No. US 2002/0035224 A1, and CN 1053925 corresponds to U.S. Patent No. 5,055,540.

Since the enclosed patents were cited by the Chinese Patent Office not more than three months prior to the submission of this Information Disclosure Statement, it is believed that no fee is required for consideration of these patents. However, the Examiner is hereby

authorized to charge any fees which may become due in connection with this communication  
or credit any overpayment to Deposit Account No. 18-2220.

Respectfully submitted,



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Dated: \_\_\_\_\_

*July 8, 2003*